



IPW

ATTORNEY'S DOCKET NO.: S1022.81021US00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Daniel BENSANEL
Serial No.: 10/614,675
Filed: July 7, 2003
For: GROWTH OF A SINGLE-CRYSTAL REGION OF A III-V
COMPOUND ON A SINGLE-CRYSTAL SILICON SUBSTRATE

Examiner: Felisa C. Hiteshew
Art Unit: 1765

Confirmation No.: 7318

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Transmitted herewith for filing is/are the following document(s):

- ☒ Response to Restriction Requirement
- ☒ Return Post Card

If the enclosed papers are considered incomplete, the Mail Room and/or the Application Branch is respectfully requested to contact the undersigned collect at (617)646-8000, Boston, Massachusetts.

No check is enclosed. If it is determined that a fee is necessary, the fee may be charged to the account of the undersigned, Deposit Account No. 23/2825. A duplicate of this sheet is enclosed.

CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)

I hereby certify that this document is being placed in the United States mail with first-class postage attached, addressed to Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on March 7, 2005.

Attorney Docket No.: S1022.81021US00
X03/11/05

Respectfully submitted,

Daniel Bensanel, Applicant

James H. Morris
Reg. No.: 34,681
WOLF, GREENFIELD & SACKS, P.C.
600 Atlantic Avenue
Boston, Massachusetts 02210
Tel. (617) 646.8000



ATTORNEY'S DOCKET NO.: S1022.81021US00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Daniel BENSAHEL
Serial No.: 10/614,675
Filed: July 7, 2003
For: GROWTH OF A SINGLE-CRYSTAL REGION OF A III-V COMPOUND ON
A SINGLE-CRYSTAL SILICON SUBSTRATE

Examiner: Felisa C. Hiteshew
Art Unit: 1765

Confirmation No.: 7318

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

ELECTION

The applicant hereby elects the claims of Group I, namely claims 1-8 drawn to device comprising a single-crystal silicon substrate, classified in Class 117, subclass 89+.

REMARKS

In response to the Patent Office action of February 11, 2005, the applicant respectfully requests reconsideration. In the Patent Office letter the Examiner has set forth a restriction requirement including claims 1-8 in Group I and claims 9-10 in Group II. By the foregoing, the applicant has now made the election of the claims of Group I, namely claims 1-8.

Having made this election, applicant expressly reserves the right to file one or more divisional applications on the subject matter of the non-elected claims.